L	Hits	Search Text	DB	Time stamp
Number			<u> </u>	
1	35	(collar with nitride with \$20xide) and ((deep adj1 trench) same (shallow adj1 trench)) and ((hard adj1 mask) hardmask photoresist mask).bi.	USPAT	2004/02/03
2	19	((collar with nitride with \$20xide) and ((deep adj1 trench) same (shallow adj1 trench)) and ((hard adj1 mask) hardmask photoresist mask).bi.) and ((shallow adj1 trench) with (\$20xide nitride))	USPAT	2004/02/03
3	14	((collar with nitride with \$20xide) and ((deep adj1 trench) same (shallow adj1 trench)) and ((hard adj1 mask) hardmask photoresist mask).bi.) and ((shallow adj1 trench adj1 isolation) with (\$20xide nitride))	USPAT	2004/02/03
_	7	(yan-jiang shum-danny-pak-chum).in.	USPAT; US-PGPUB; EPO; DERWENT	2004/01/29
-	1	"20040005753"	USPAT; US-PGPUB	2004/01/23
-	1	("6355106").PN.	USPAT	2004/01/23
-	1241	(self adj1 align\$3) same (isolation STI) same (trench opening recess).bi.	USPAT	2004/01/29
-	436		USPAT	2004/02/03 09:21
-	1		USPAT	2004/01/29 12:52